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OSTROLENK, FABER, GERB & SOFFEN, LLP

1180 AVENUE OF THE AMERICAS, NEW YORK, NEW YORK 10036-8403

TEL 212 382 0700 FAX 212 382 0888 FAX 212 398 0681

email@ostrolenk.com

PARTNERSSAMUEL H. WEINER
ROBERT C. FABER
MAX MOSKOWITZ
JAMES A. FINDER
WILLIAM O. GRAY, III
LOUIS C. DUMICHCHARLES P. LAPOLLA
DOUGLAS A. MIRO
PETER S. SLOANE**ASSOCIATES**JOEL J. FELBER**
KOUROSH SALEHI**
DOUGLAS Q. HAHN
GLEN R. FARBANISH
MICHAEL I. MARKOWITZ
CHARLES P. GUARINOCINDY YANG
KEITH J. BARKAUS**OF COUNSEL**MARTIN PFEFFER
LAWRENCE A. HOFFMAN
MARTIN J. BERAN
PAUL GRANDINETTI*
KLAUS P. STOFFEL
MARK A. FARLEY**WASHINGTON OFFICE**1725 K STREET, N.W.
WASHINGTON, D.C. 20006
TEL 202 457 7785
FAX 202 429 8919*DC BAR
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MESSAGE:Applicant: Carl L.C. Kah III
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Transmitted herewith is an Amendment and an Information Disclosure Statement in connection with the above-identified patent application.